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INFO	DMATION I)ISCI	OSURE	Application Number	08/781,920	
INFORMATION DISCLOSURE				Filing Date	December 30, 1996	
STATEMENT BY APPLICANT				First Named Inventor	Takeshi FUKUNAGA et al.	
	(use as many sheets o	is necessa	iry)	Group Art Unit	1762	
				Examiner Name	M. PADGETT	
Sheet	1	of	1	Attorney Docket Number	740756-1614	

				U.S. PATENT DOCUMEN	TS ·		
Examiner Initials	Cite No.1	U.S. Patent Document		Name of Patentee or Applicant of Cited	Date of Publication of Cited Document MM-DD-YYYY	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear	
		Number	Kind Code ² (if known)	Document	MINI-DD-1111		
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	7-283135	Sharp Corp.	Oct. 27, 1995	US 5,419,044	Abstract			
	8-8181	Sharp Corp.	Jan. 12, 1996 \ =	USPN 5,696,003	Abstract			
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	OTHER PRIOR A	ART – NON PATENT LITE	RATURE DOCUMENTS					
Cite No.1	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.)., date, page(s), volume-issue number(s), publisher, city and/or country where published.							
2	KAWAZU et al., "Low-Temperature Crystallization of Hydrogenated Amorphous Silicon Induced by Nickel Silicide Formation", Japanese Journal of Applied Physics, Vol. 29, No. 12, Dec. 1990, pp 2698-2704.							
	No. 1	Cite No.1 Foreign Patent Document Office3 Number4 Kind Code3 (if known) 7-283135 8-8181 OTHER PRIOR Cite No.1 Include name of the auth item (book, magazine, journal of the sund item (book, magazine, journal of the litem) KAWAZU et al., "Low-Tell Induced by Nickel Silicides	Cite No. 1 Foreign Patent Document Name of Patentee or Applicant of Cited Document 7-283135 Sharp Corp. 8-8181 Sharp Corp. OTHER PRIOR ART – NON PATENT LITE Cite No. 1 Include name of the author (in CAPITAL LETTERS), item (book, magazine, journal, serial, symposium, catal publisher, city and/or count KAWAZU et al., "Low-Temperature Crystalliz, Induced by Nickel Silicide Formation", Japanes	Name of Patentee or Applicant of Cited Document Name of Patentee or Applicant of Cited Document	Cite No. Foreign Patent Document Name of Patentee or Office' Number' Kind Code' (if known) Name of Patentee or Applicant of Cited Document MM-DD-YYYY Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear 7-283135 Sharp Corp. Oct. 27, 1995 W5 8, 417,044 8-8181 Sharp Corp. Jan. 12, 1996 Jan. 12, 1996 Jan. 12, 1996 Jan. 12, 1996 OTHER PRIOR ART - NON PATENT LITERATURE DOCUMENTS Cite No. Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.)., date, page(s), volume-issue number(s), publisher, city and/or country where published. KAWAZU et al., "Low-Temperature Crystallization of Hydrogenated Amorphous Silic Induced by Nickel Silicide Formation", Japanese Journal of Applied Physics, Vol. 29, No. 20, No. 29, No. 20, No. 29, No. 20, No. 20			

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